

162	Subclass	ASSIFICATION
429	Class	SSUE CLA





U.S. UTILITY Patent Application

O.I.P.E.	PATENT DATE	
SCANNED HKMO GA	MAY 0 6 2003	 <i>i</i> ,

	PLICATION NO. 09/779595	CONT/PRIOR	<b>CLASS</b> 429	SUBCLASS	<b>ART UNIT</b> 1745	EXAMINER MADE	
UCANTS	Jay Whitac Ratnakumar William We	- Bugga		- <del></del>			،
APF	Structure microbatte		od for m	anufactur	ing thin-1	Film lithium	
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**ISSUING CLASSIFICATION** 

	ORIGINA	INAL CRO			CROSS R	REFERENCE(S)				
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TERMINAL			DRAWINGS				CLAIMS ALLOWED			
DISCLAIMER Sheets Drwg. Fi		gs. Drwg.	Print Fig.	Total	Total Claims Print Claim					
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WARNIN The information of the control of the contro	ation disclose	ed herein may be res U.S. Patent & Traden	itricted. Unauthorized disclonark Office is restricted to au	sure may be p thorized emplo	rohibited by the yees and contra	United States actors only.	s Code Title 3	5, Sections 122, 1	181 and 368.	
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